L Number	Hits	Search Text	DB	Time stamp
1	50081	(electron adj beam) and substrate	USPAT;	2004/04/22 11:14
			US-PGPUB;	
ļ			EPO; JPO;	
			IBM_TDB	
2	14196	((electron adj beam) and substrate) and stage	USPAT;	2004/04/22 11:14
			US-PGPUB;	·
			EPO; JPO;	
			IBM_TDB	
3	2841	(((electron adj beam) and substrate) and stage) and focus	USPAT;	2004/04/22 11:14
			US-PGPUB;	
			EPO; JPO;	
			IBM_TDB	
4	98	((((electron adj beam) and substrate) and stage) and focus)	USPAT;	2004/04/22 11:15
·		and (surface adj charge)	US-PGPUB;	,, - ,,
			EPO; JPO;	
			IBM_TDB	
5	96	(((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:15
Ĭ	30	focus) and (surface adj charge)) and area	US-PGPUB;	2001/01/22 11:15
		l locasi and (sarrace day anarge)) and area	EPO; JPO;	
			IBM_TDB	
6	96	(((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:15
0	50	focus) and (surface adj charge)) and area	US-PGPUB;	2004/04/22 11.13
l		Tocus) and (surface adjurial ge)) and area	EPO; JPO;	
			IBM_TDB	
7	52	((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:16
′	32	focus) and (surface adj charge)) and area) and bias	US-PGPUB;	2004/04/22 11.10
		Tocus) and (surface adjurial ge)) and area) and bias	EPO; JPO;	
			IBM_TDB	
	25	((((()alactron adi boam) and substrato) and stage) and	USPAT;	2004/04/22 11:16
8	25	((((((electron adj beam) and substrate) and stage) and	1	2004/04/22 11.10
		focus) and (surface adj charge)) and area) and (bias adj	US-PGPUB;	
		voltage)	EPO; JPO;	
	25	//////olostwon adi bosm) and substrate) and stage) and	IBM_TDB	2004/04/22 11:17
9	25	(((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:17
		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)	EPO; JPO;	
10		((((((((a)a)a)a)a)a)a)a(((((((((a)a)a)a)a)a)a)a((((((IBM_TDB	2004/04/22 44:20
10	1	(((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:38
		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)) and (bias near4 level)	EPO; JPO;	
			IBM_TDB	2004/04/20 11 22
11	25	((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:39
		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)) and level	EPO; JPO;	
			IBM_TDB	
12	25	((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:39
:		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)) and voltage	EPO; JPO;	
			IBM_TDB	

L Number	Hits	Search Text	DB	Time stamp
1	6	((((((((((((((((((((((((((((((((((((((USPAT;	2004/04/22 14:13
		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)) and level) and flood	EPO; JPO;	
			IBM_TDB	
2	1	"20020130260"	USPAT;	2004/04/22 14:15
	-		US-PGPUB;	
			EPO; JPO;	
			IBM_TDB	
-	E0001	(alastron adi baam) and substrato	USPAT;	2004/04/22 11:14
	50081	(electron adj beam) and substrate		2004/04/22 11:14
			US-PGPUB;	
			EPO; JPO;	
			IBM_TDB	
-	14196	((electron adj beam) and substrate) and stage	USPAT;	2004/04/22 11:14
			US-PGPUB;	
			EPO; JPO;	
1			IBM_TDB	
-	2841	(((electron adj beam) and substrate) and stage) and focus	USPAT;	2004/04/22 11:14
ì		(((US-PGPUB;	' '
i			EPO; JPO;	
			IBM_TDB	
_	98	((((electron adj beam) and substrate) and stage) and focus)	USPAT;	2004/04/22 11:15
-	90			2004/04/22 11.13
		and (surface adj charge)	US-PGPUB;	
			EPO; JPO;	
			IBM_TDB	
-	96	(((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:15
		focus) and (surface adj charge)) and area	US-PGPUB;	
			EPO; JPO;	
			IBM_TDB	
-	96	(((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:15
		focus) and (surface adj charge)) and area	US-PGPUB;	
[,, (EPO; JPO;	
			IBM_TDB	
_	52	(((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:16
	32	focus) and (surface adj charge)) and area) and bias	US-PGPUB;	200 1/0 1/22 11.10
		locus) and (surface adjuriar ge)) and area) and bias		
			EPO; JPO;	
	25	(U)U() but a condition only beauty and advantable and about a condition of	IBM_TDB	2004/04/22 11:10
-	25	((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:16
		focus) and (surface adj charge)) and area) and (bias adj	US-PGPUB;	
		voltage)	EPO; JPO;	
			IBM_TDB	
-	25	(((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:17
		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)	EPO; JPO;	
			IBM_TDB	l -
-	1	((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:38
	_	focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	, , , , , , , , , , , , , , , , , , , ,
		(bias adj voltage)) and (bias near4 level)	EPO; JPO;	
		(blas day voltage)) and (blas float i level)	IBM_TDB	
-	25	((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:39
	23			2007/07/22 11.39
		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)) and voltage	EPO; JPO;	
			IBM_TDB	0004/5-195-1-1-1
-	25	((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 14:04
		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)) and level	EPO; JPO;	
			IBM_TDB	